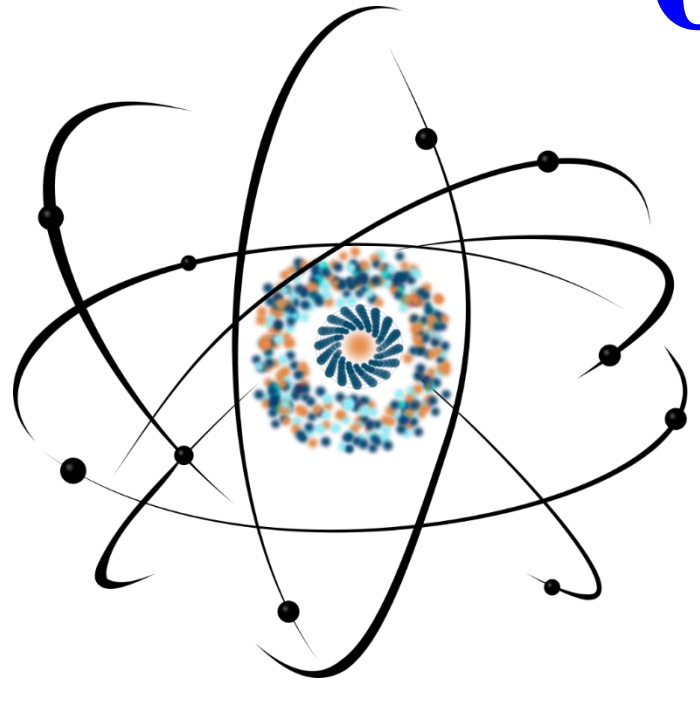


Approaches to fabrication and characterizing of ceramic-based thick-film nanostructures for sensor applications



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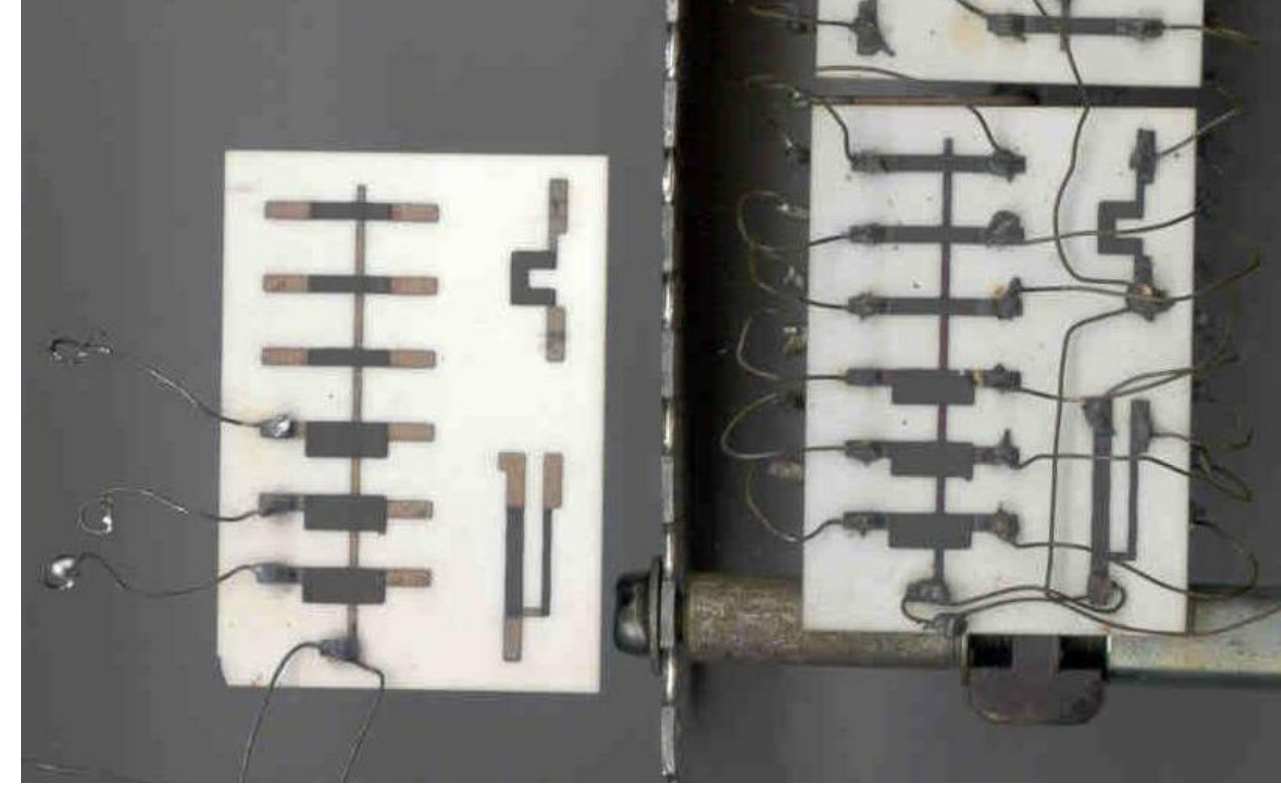
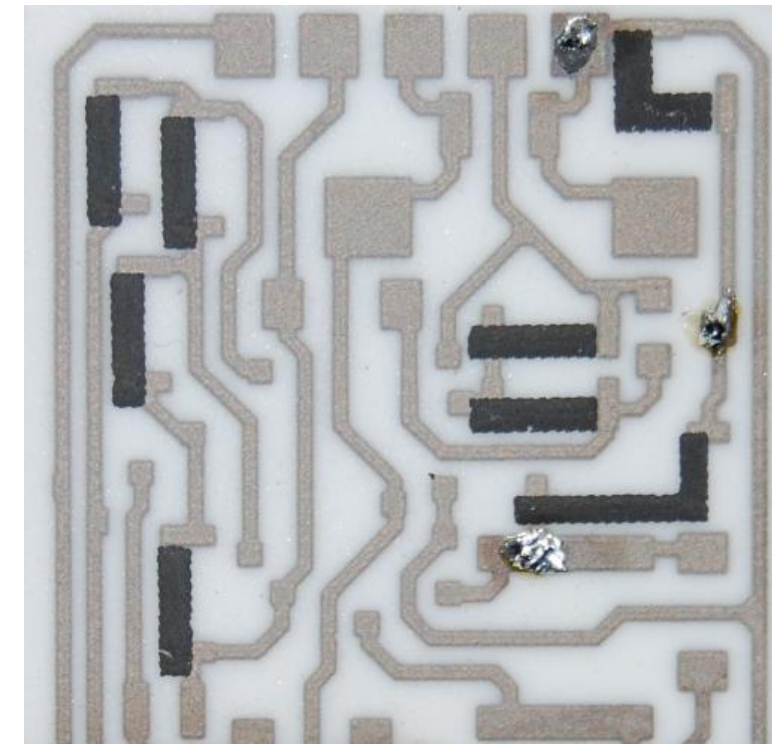
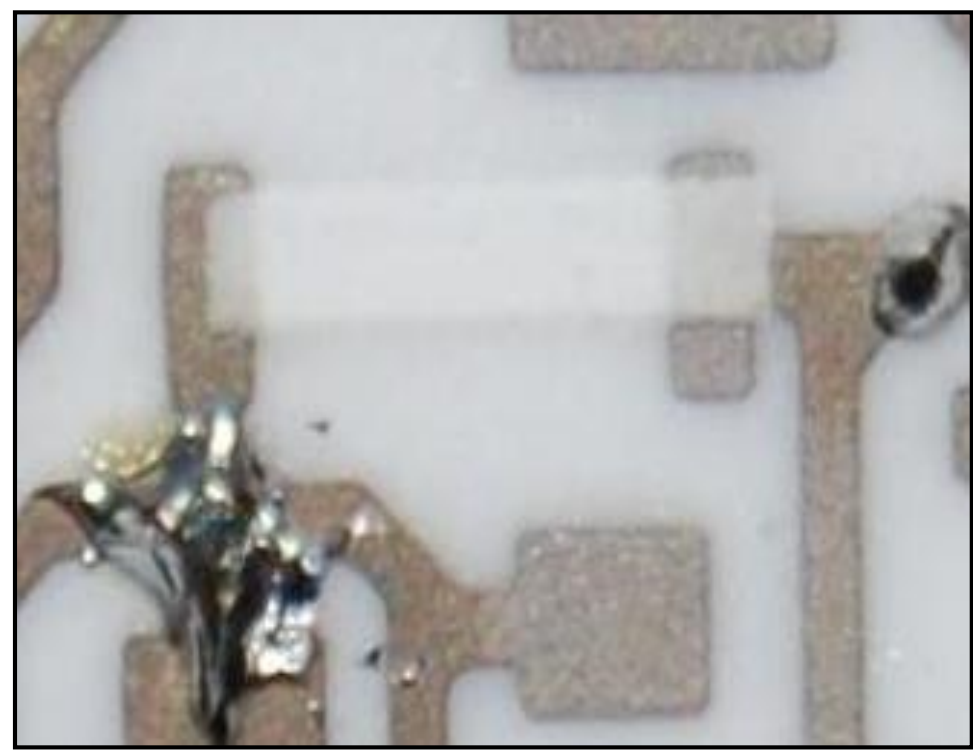
³Drohobych Ivan Franko State Pedagogical University, Drohobych, Ukraine



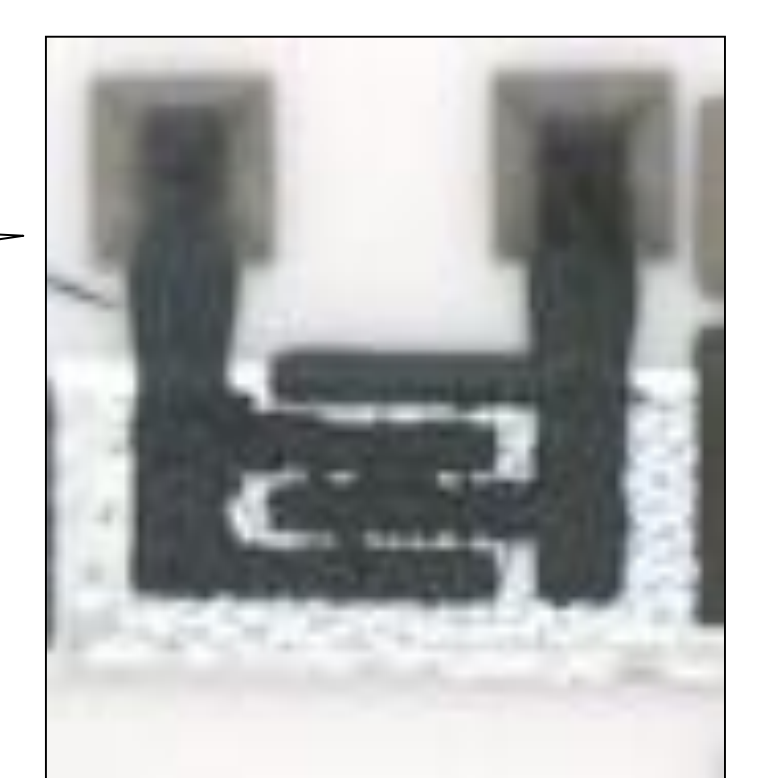
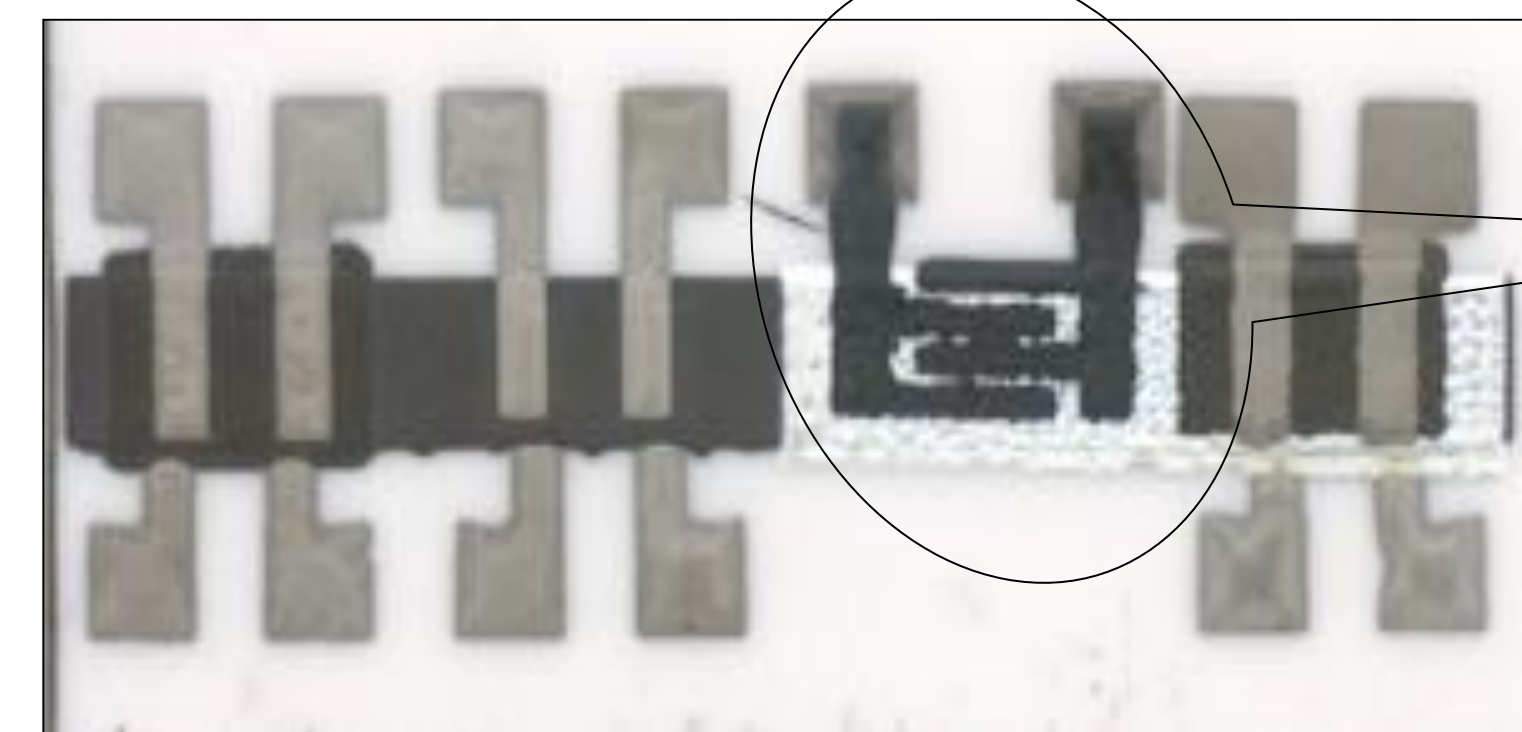
Phase composition and microstructural properties thick-film nanostructures based on humidity-sensitive MgO-Al₂O₃, temperature-sensitive Cu_{0,1}Ni_{0,1}Co_{1,6}Mn_{1,2}O₄ and Cu_{0,1}Ni_{0,8}Co_{0,2}Mn_{1,9}O₄ ceramics were investigated. Temperature-sensitive thick films contain three phase, while humidity-sensitive thick films are practically monophase. Pores in temperature-sensitive thick-film nanostructures are formed in clusters, while humidity-sensitive layers contain a significant amount of small pores, which serve as channels for the flow of water to nanopores.

Active elements of temperature- and humidity-sensitive thick-film nanostructures

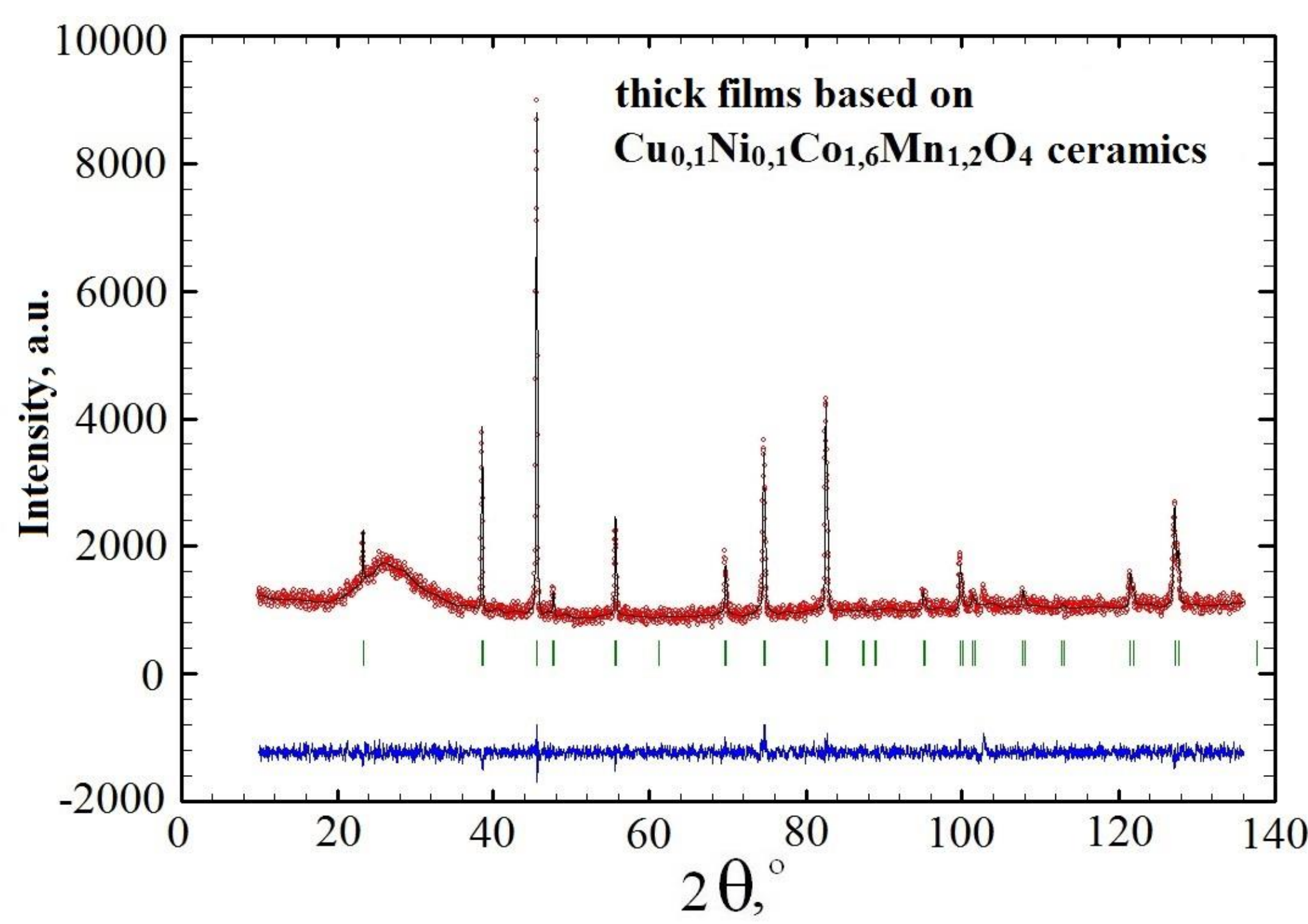
Humidity-sensitive i-type MgO-Al₂O₃ Temperature-sensitive Cu_{0,1}Ni_{0,1}Co_{1,6}Mn_{1,2}O₄



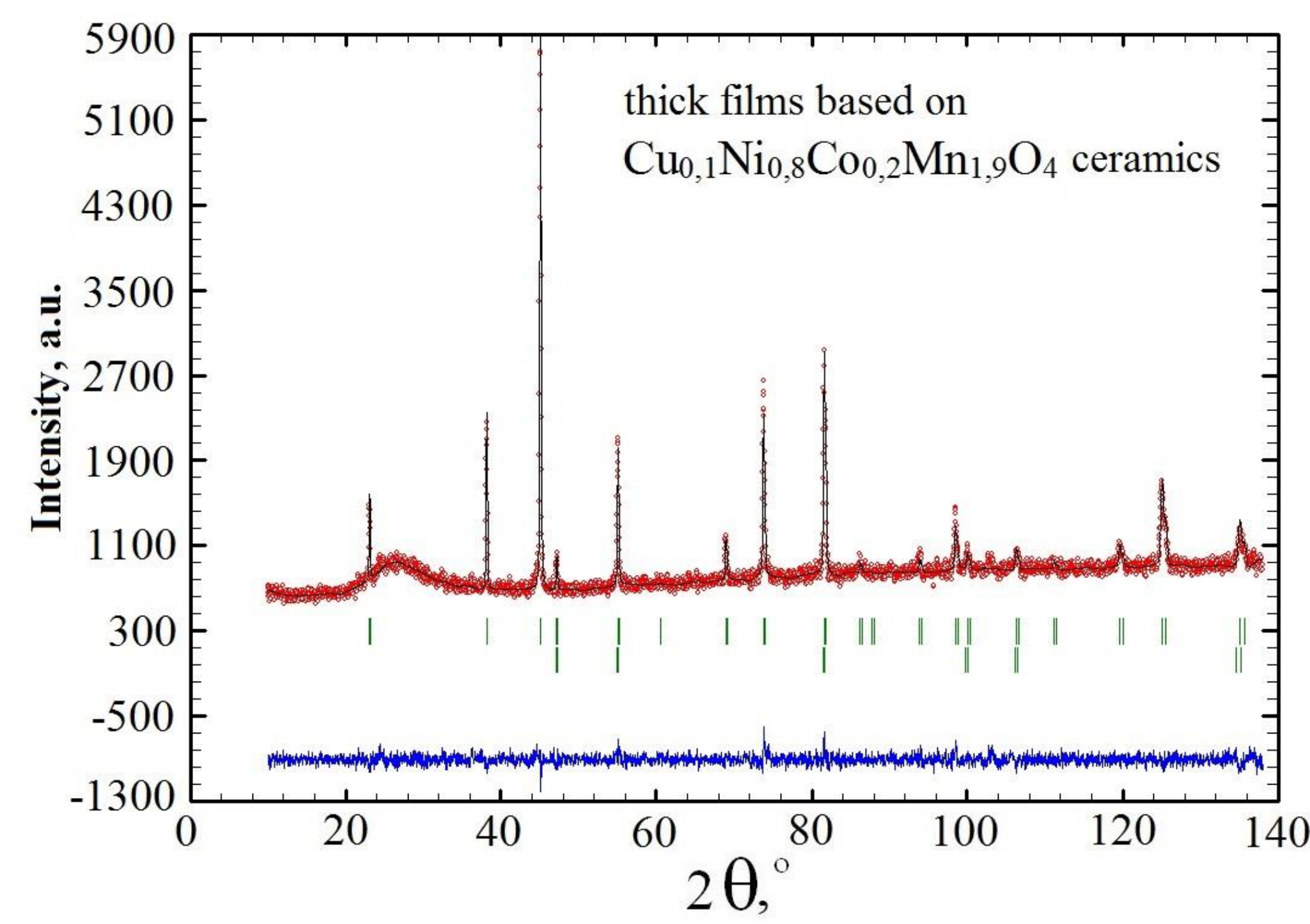
Integrated p-i-p+ temperature- and humidity-sensitive thick-film structures



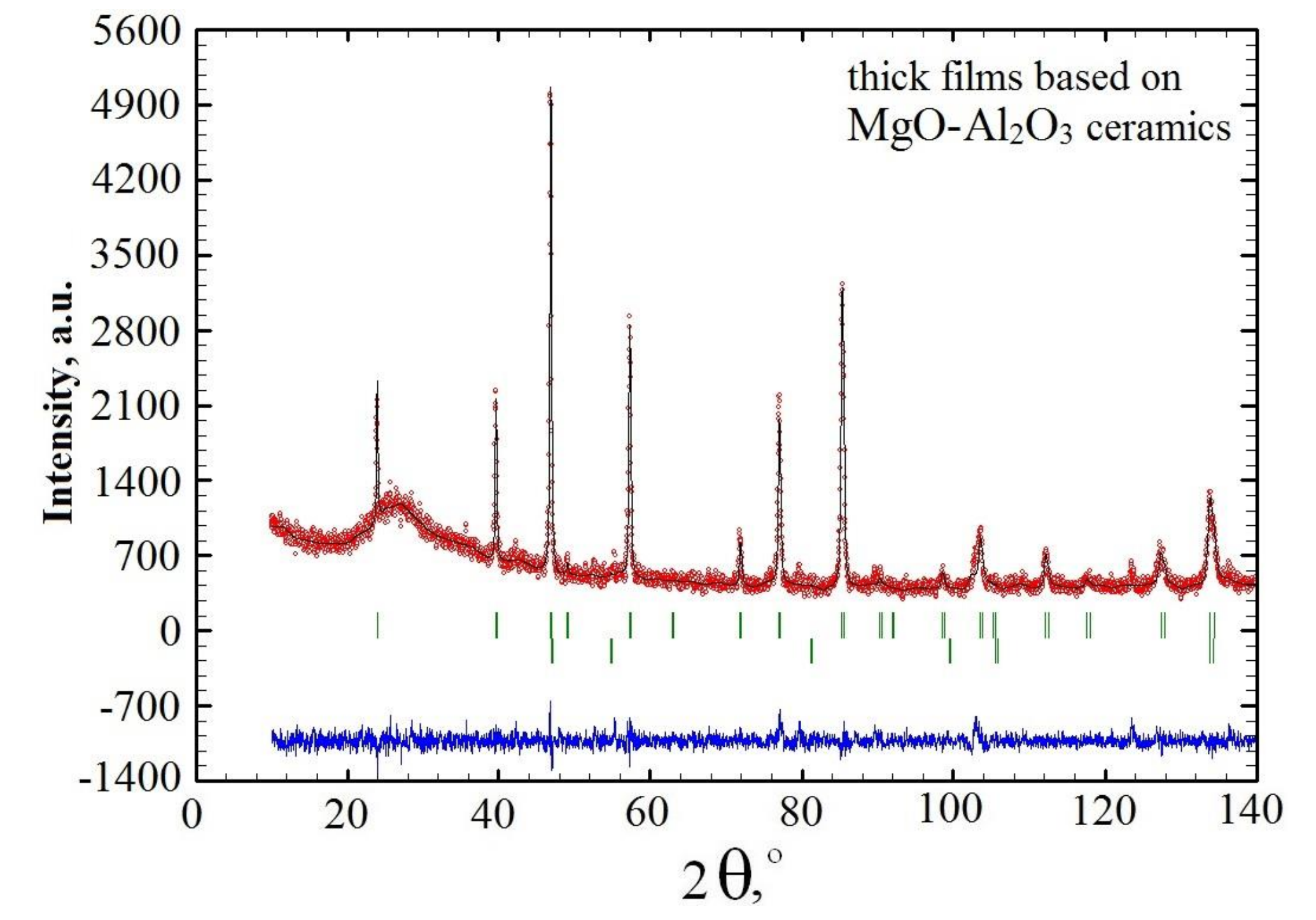
Phase compositions of thick-film structures



Experimental (rings), theoretical (solid line) and the difference (below) of X-ray diffraction patterns for Cu_{0,1}Ni_{0,1}Co_{1,6}Mn_{1,2}O₄ thick films

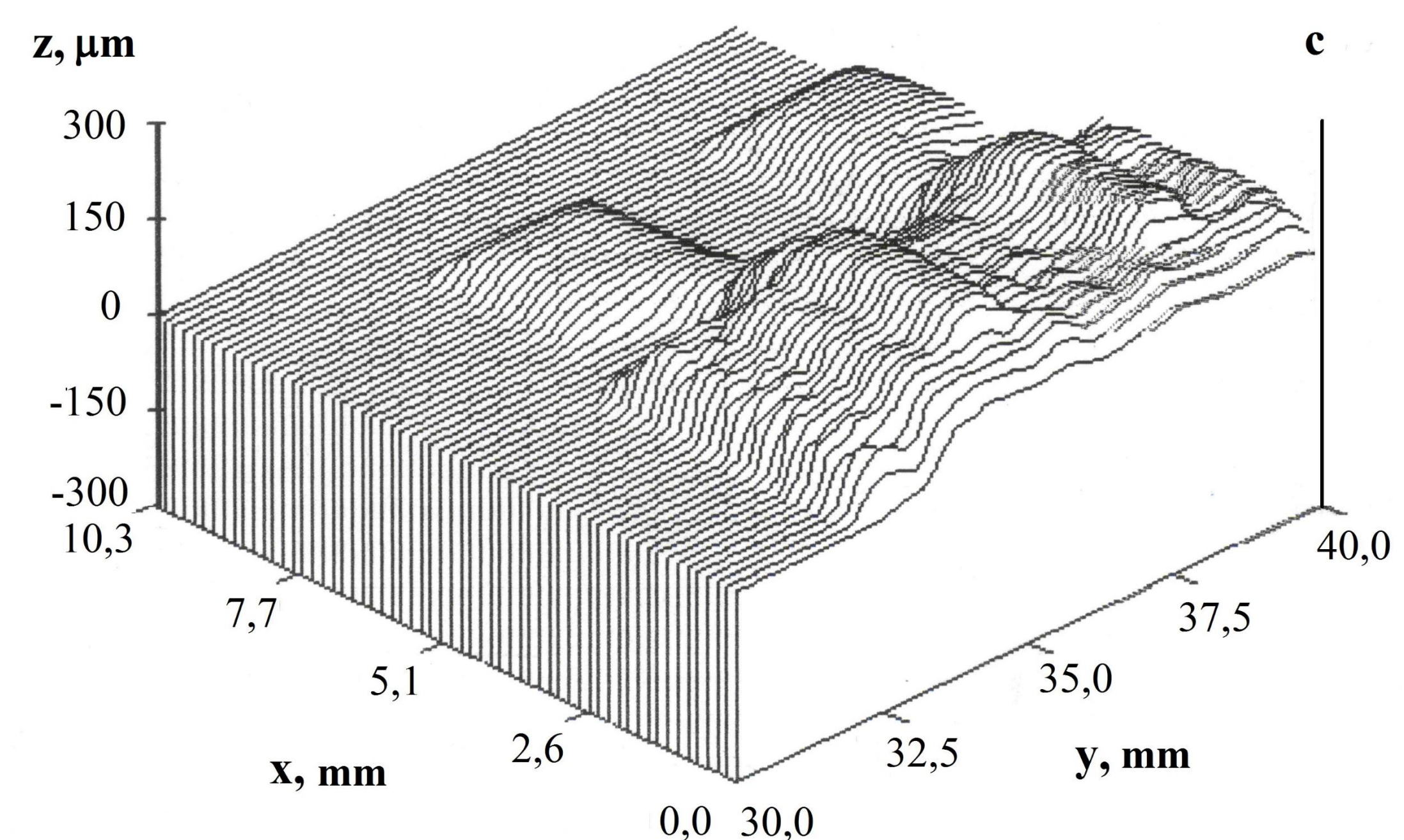
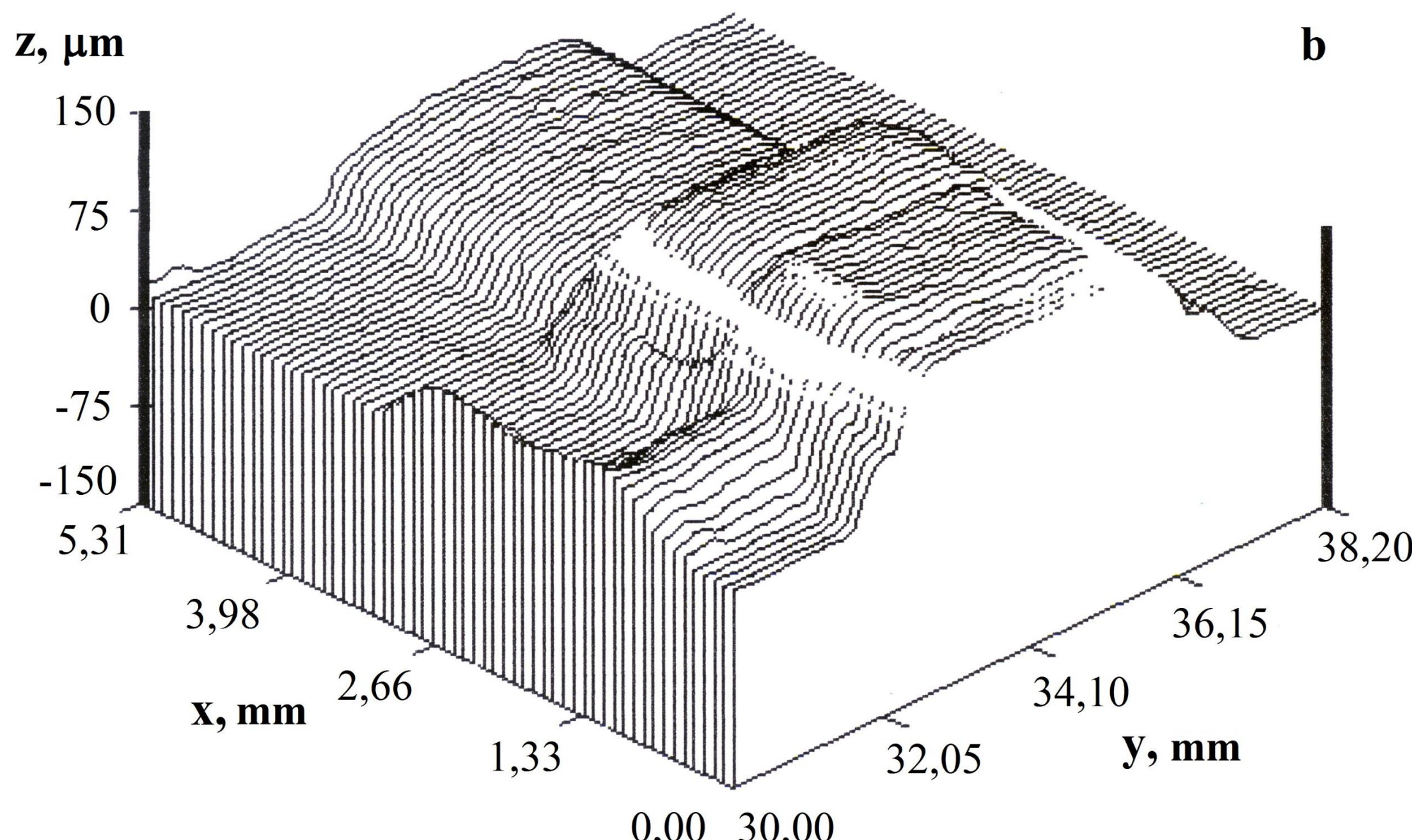
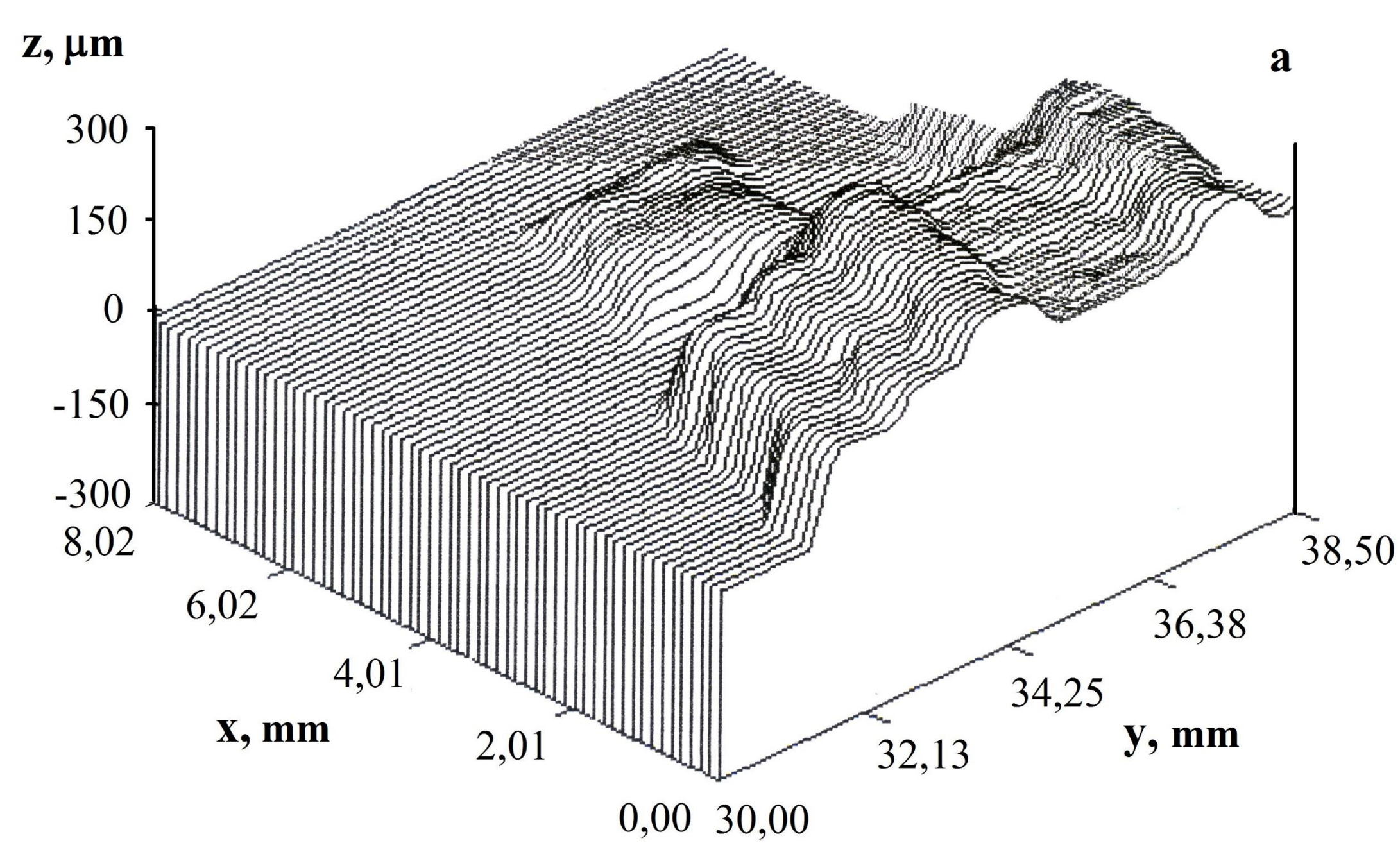


Experimental (rings), theoretical (solid line) and the difference (below) X-ray diffraction pattern for Cu_{0,1}Ni_{0,8}Co_{0,2}Mn_{1,9}O₄ thick film (the upper series of reflex marks is the spinel phase, the lower one is (Ni_{1-x}Mn_x)O)



Experimental (rings), theoretical (solid line) and the difference (below) X-ray diffraction pattern for MgO-Al₂O₃ thick films (the upper series of reflex marks is the spinel phase, the lower one is MgO)

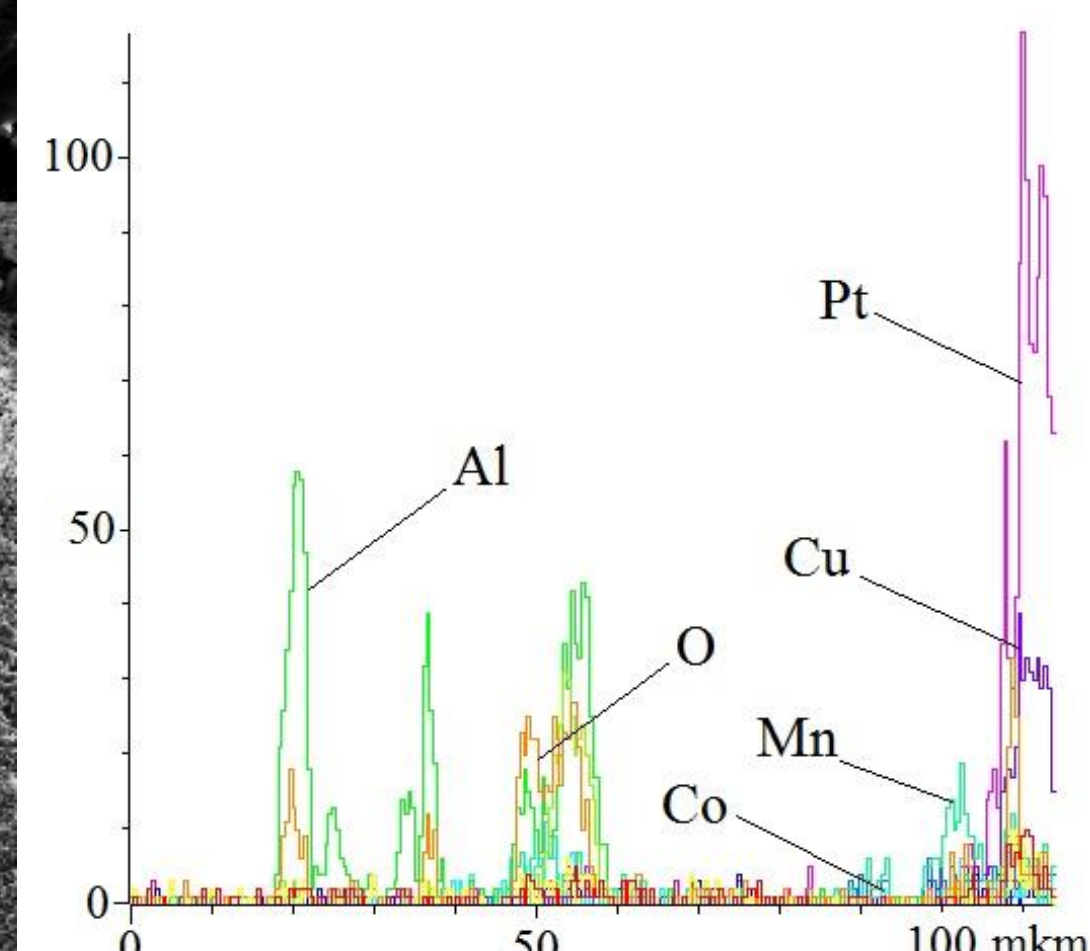
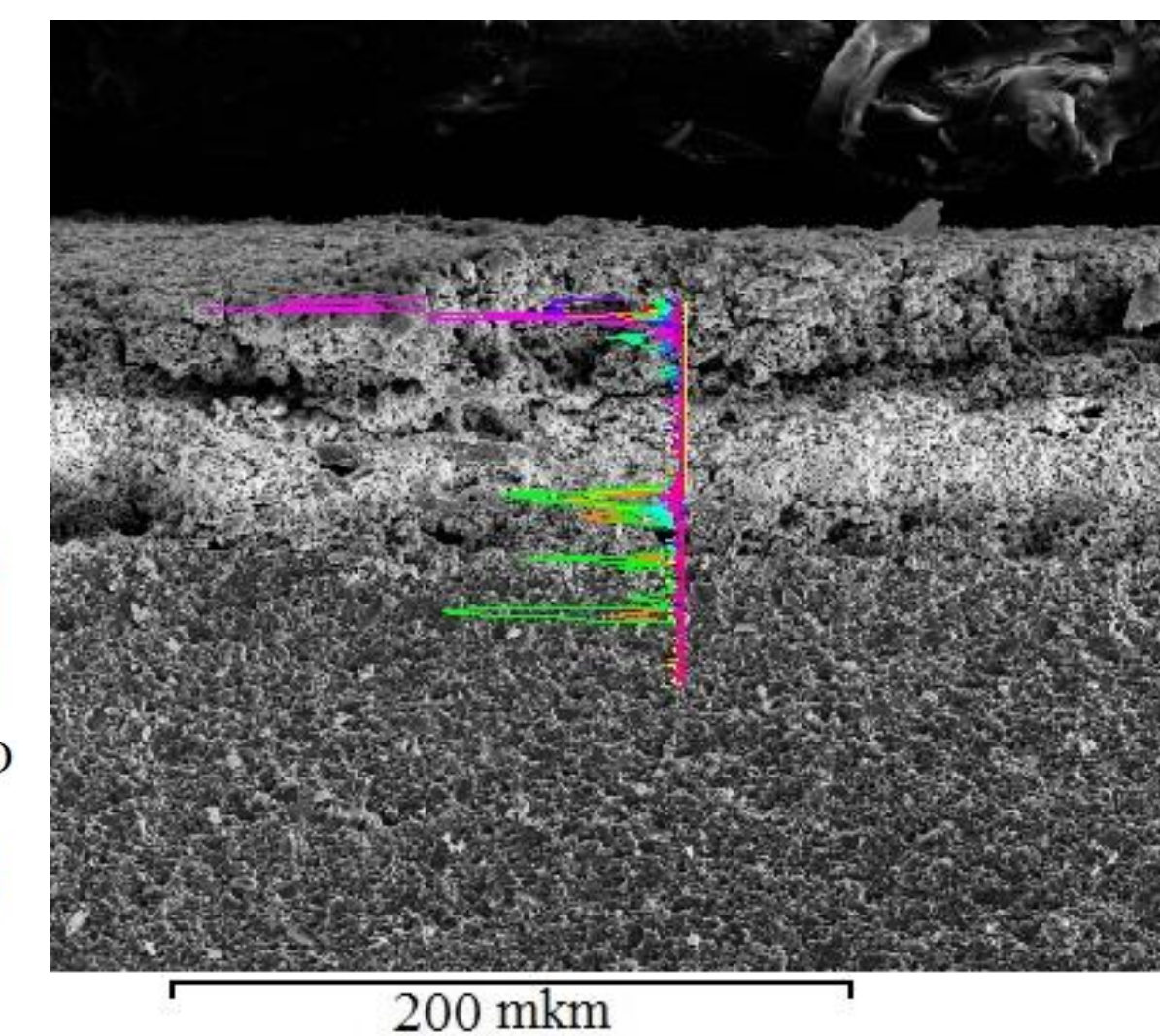
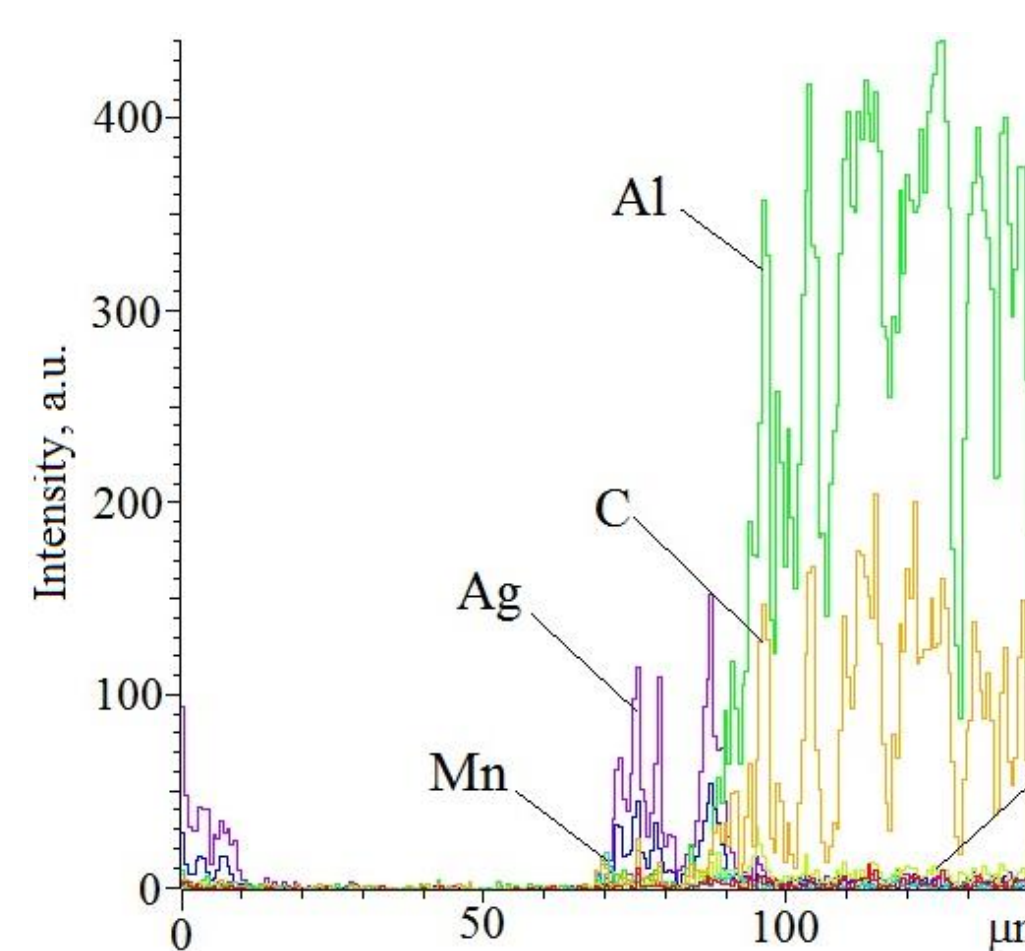
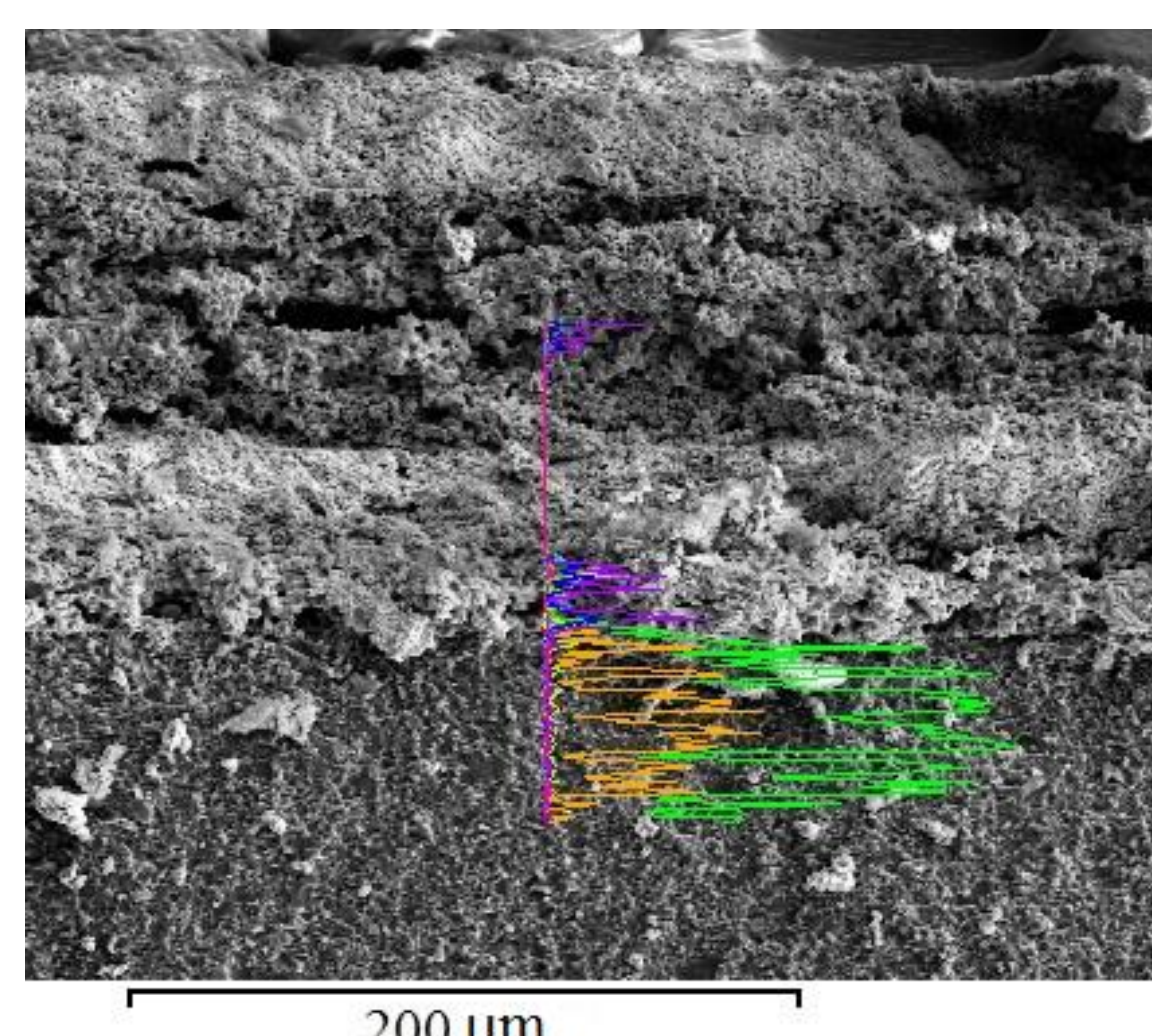
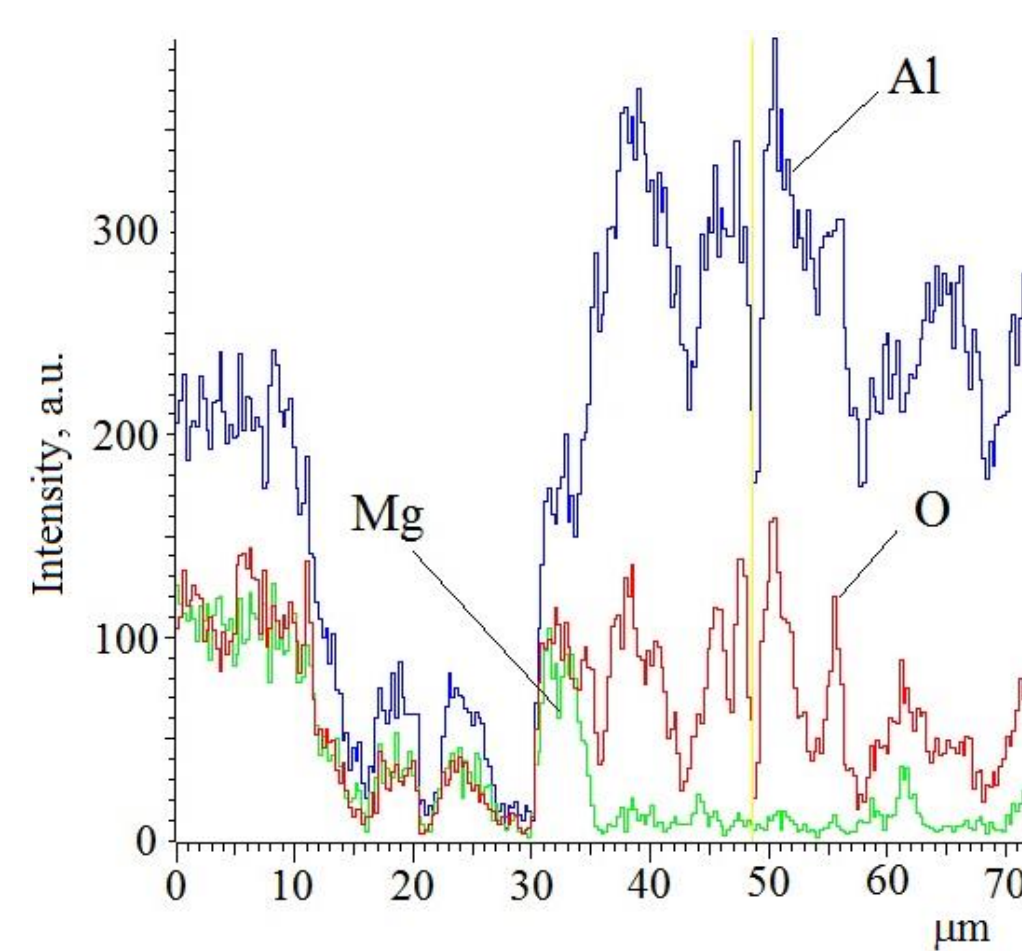
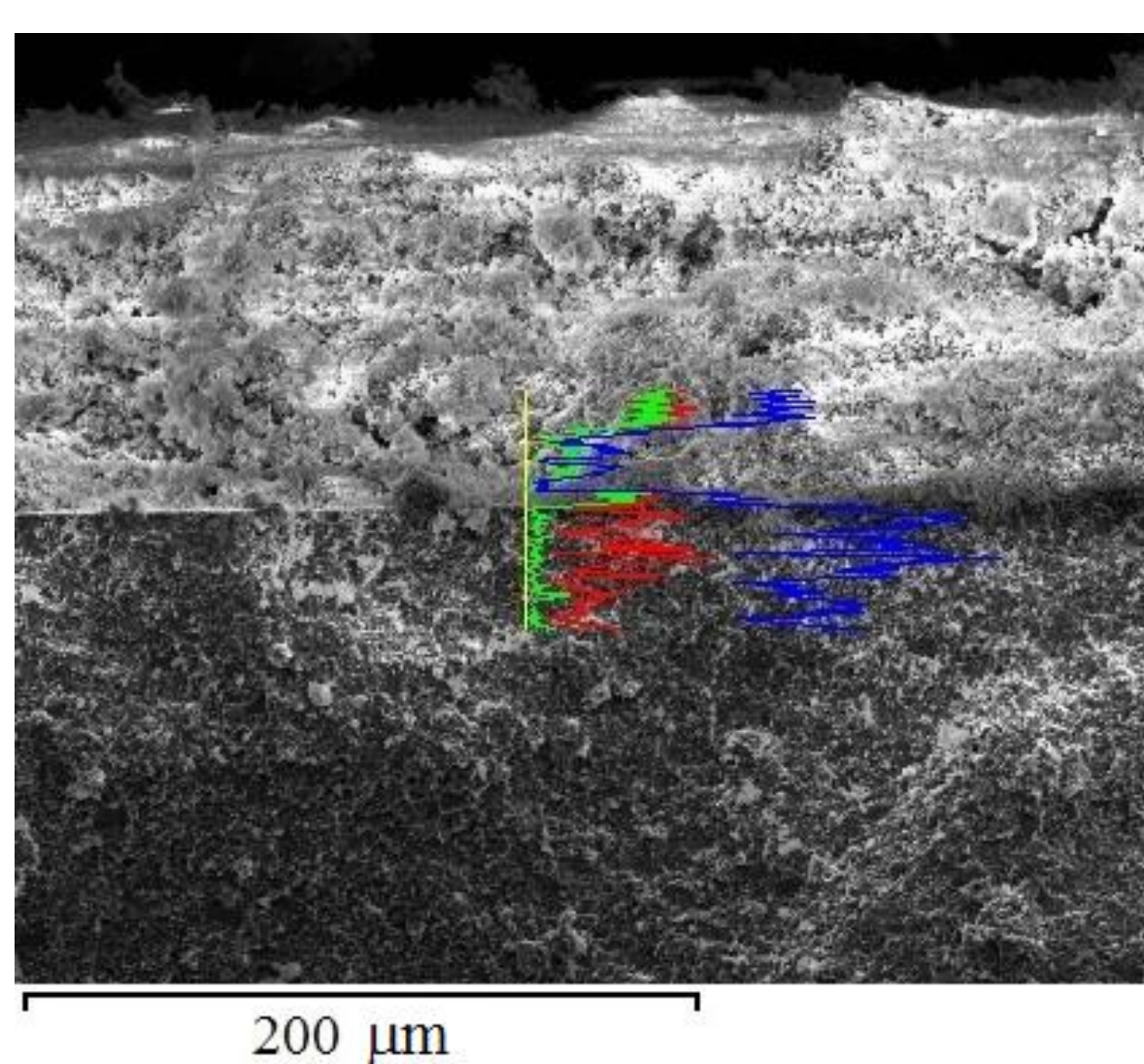
Topology of thick-film structures



Topology of p-p⁺ (a), p⁺-i (b) and integrated p-i-p⁺ (c) thick-film structures

In accordance with results of topological investigations using 3D-profilograph Rodenstock RM600 (Germany), thickness of temperature-sensitive p- and p⁺-layers was 43.75 μm and 46.88 μm, accordingly. The of two-layered p⁺-i thick-film structure is 139.06 μm, p⁺-p – 110.16 μm, and integrated p-i-p⁺ thick-film structures with conductive Ag layer – 193.73 μm (thickness of Ag layer is 45.31 μm).

Microstructure of thick-film structures



Microstructure and element composition of humidity-sensitive MgO-Al₂O₃ thick films formed as two-layered structure on Rubalit (Al₂O₃) substrate with formed conductive Ag layer

Microstructure and element composition of one-layered temperature-sensitive thick films formed as on Rubalit (Al₂O₃) substrate with formed conductive Ag layer

Microstructure and element composition of two-layered p⁺-i structure formed on substrate with conductive layer